



MS ISSUE FEE  
PATENT  
0760-0296P

IN THE U.S. PATENT AND TRADEMARK OFFICE

Applicant: Hiroshi ITATANI et al. Conf.: 9966  
Appl. No.: 09/980,212 Group: 1752  
Filed: March 18, 2002 Examiner: R. Ashton  
For: METHOD FOR FORMING POLYIMIDE PATTERN USING  
PHOTOSENSITIVE POLYIMIDE AND COMPOSITION THEREFOR

**AMENDMENT UNDER 37 C.F.R. § 1.312**

HANDCARRY TO:  
U.S. Patent and Trademark Office  
2011 South Clark Place  
Customer Window  
Crystal Plaza Two, Lobby, Room 1B03  
Arlington, VA 22202

April 21, 2004

Sir:

Pursuant to the provisions of 37 C.F.R. § 1.312, the following amendments and remarks are respectfully submitted in connection with the above-identified application. It is respectfully requested that the following amendments be entered without withdrawing the application from issue.

**Amendments to the Claims** are reflected in the listing of claims which begins on page 2 of this paper.

**Remarks** begin on page 7 of this paper.